

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	83	Goldbach.inv. same Matthias	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/02 14:14
S2	1	Goldbach.inv. same Matthias and trench and substrate and "horizontal mask" and "vertical mask" and anisotropic and sidewall and etch\$4 and dielectric and electrode and capacitor and insulator and connection	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/02 14:17
S3	1	Goldbach.inv. same Matthias and trench and substrate and "horizontal mask" and "vertical mask" and anisotropic and sidewall and etch\$4 and dielectric and electrode and capacitor	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/02 14:17
S4	1	Goldbach.inv. same Matthias and trench and substrate and "horizontal mask" and "vertical mask" and anisotropic	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/02 14:17
S5	37	Goldbach.inv. same Matthias and trench and substrate and mask	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/02 14:17
S6	23	Goldbach.inv. same Matthias and trench and substrate and mask and anisotropic	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/02 14:18
S7	19	Goldbach.inv. same Matthias and trench and substrate and mask and anisotropic and etch\$4 and dop\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/02 14:18
S8	18	Goldbach.inv. same Matthias and trench and substrate and mask and anisotropic and etch\$4 and dop\$4 and dielectric	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/02 14:18
S9	8	Goldbach.inv. same Matthias and trench and substrate and mask and anisotropic and etch\$4 and dop\$4 and dielectric and insulator	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/02 14:18
S10	7	Goldbach.inv. same Matthias and trench and substrate and mask and anisotropic and etch\$4 and dop\$4 and dielectric and insulator and connection	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/02 14:27

S11	44	"5658816"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/02 14:27
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